

METHOD FOR THE MANUFACTURE OF A LIQUID CRYSTAL DISPLAY

Abstract of the Disclosure

5 The method uses one photomask and one-exposure
steps wherein said photomask comprising two major
portions that are formed by mirror image with each other,
the widths of openings formed in said photomask being
increased from a central portion to an edge portion, the
10 spaces between two adjacent said openings being decreased
from said central portion to said edge. Then, shift said
substrate with a distance to a direction perpendicular to a
surface of said photomask. Next, expose said photosensitive
material layer by using said photomask; and developing the
15 photosensitive material to form said bump structure